

## Preface

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This Special Issue of *Research on Chemical Intermediates* follows the Chinese National Conference on Solar Photochemistry and Photocatalysis, which was held at the Shanghai Normal University, Shanghai, China, November 2–4, 2008. The aim of this conference was to provide an overview of the new progress and latest findings with bi-annual background and deep insight into the opportunities, challenges, and new directions in the field of photochemistry and photocatalysis. The conference was mainly dedicated to promoting the communication and linkage between scientists and industrialists. Certainly, it will greatly boost the science and technology development of photochemistry and photocatalysis in China.

The conference was successfully organized by the Shanghai Normal University under the auspices of the Photochemistry Professional Committee of the Chinese Renewable Energy Society. Although it was a Chinese scholar conference, it brought together 325 scientists, engineers, and other photochemical professionals from all over the world to present and discuss the latest research concerning all of the aspects of photochemistry and photocatalysis. Nine plenary presentations and 22 keynote lectures were addressed by famous scientists from China, Japan, and the United States. Meanwhile, over 122 oral reports and 67 posters were contributed. After reviewing a total of more than 200 papers, 18 articles with a clear focus regarding photochemistry and photocatalysis were selected for possible publication in this Special Issue.

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